REPLACEMENT CLAIMS

1. (four times amended) An etching composition consisting essentially of:

a non-aqueous composition of an alcohol and at least two inorganic acids, wherein one of said inorganic acids is selected from the group consisting of phosphoric

acid, sulfuric acid, bork acid, carbonic acid, perchloric acid and sulfurous acid.

9. (amended) The composition according to claim 1, wherein said inorganic acids are selected from the group consisting of nitric acid, phosphoric acid, sulfuric acid, boric acid, carbonic acid, perchloric acid and sulfurous acid.